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The fabrication of the ultra-thin polyvinylidene fluoride dielectric films for nanoscale high energy density capacitors

Xiong Xie, Mengbin Zhou, Luqiang Lv, Shuangyi Liu, Jun Shen



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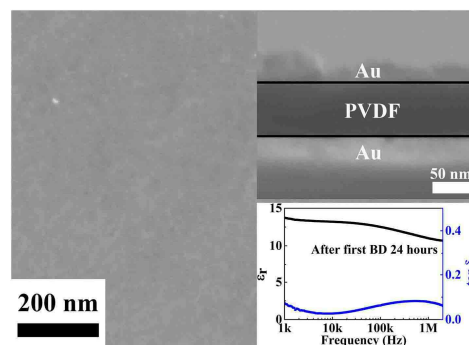
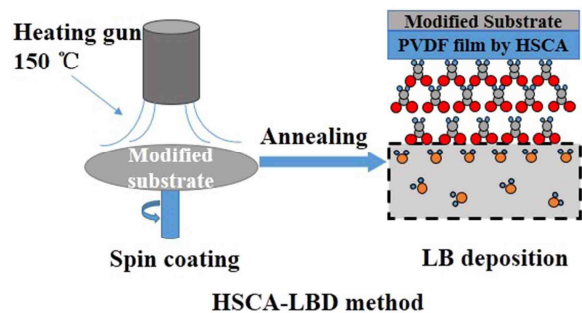
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